



PATENT APPLICATION

THE UNITED STATES PATENT AND TRADEMARK OFFICE

Date June 18, 2008

In re the Application of

Hideki SATO

Group Art Unit: 1792

Application No.: 10/594,458

Examiner: L. UINH

Filed: September 26, 2006

Docket No.: 129546

For: METHOD FOR EVALUATING CRYSTAL DEFECTS OF SILICON WAFER

**LARGE ENTITY PETITION FOR 1st - 3rd EXTENSION
OF TIME UNDER 37 C.F.R. §1.136(a) AND
TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired May 19, 2008, an extension of time for a period of 1 month is hereby requested. Attached hereto is our Check No. 206815 in the amount of \$120 in payment for:

Extension fee for response within first month pursuant to §1.136(a) (\$120.00)
 Extension fee for response within second month pursuant to §1.136(a) (\$460.00)
 Extension fee for response within third or subsequent month pursuant to §1.136(a) (\$1050.00)

The Commissioner is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461.

Respectfully submitted,

William P. Berridge
Registration No. 30,024

Nicolas A. Brentlinger
Registration No. 62,211
06/19/2008 JADDO1 00000021 10594458

WPB:NAB/mcp

01 FC:1251 120.00 0P

OLIFF & BERRIDGE, PLC
P.O. Box 320850
Alexandria, Virginia 22320-4850
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**DEPOSIT ACCOUNT USE
AUTHORIZATION**
Please grant any extension
necessary for entry;
Charge any fee due to our
Deposit Account No. 15-0461



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AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the February 19, 2008 Office Action, the statutory period for reply being extended by the attached Petition for Extension of Time, please consider the following:

Amendments to the Claims as reflected in the listing of claims; and

Remarks.